

论文

第一性原理计算TiN(111)/BN/TiN(111)界面的电子结构、成键特性和结合强度

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摘要:

利用第一性原理计算方法研究了TiN(111)/BN/TiN(111)界面的16个理论界面构型. 计算结果表明, 最稳定界面构型为top-top-BN 构型, 此构型中B原子只与周围N原子成键, 为四面体配位. 同时计算了top-top-BN构型的电子结构和成键特性以及界面结合强度, 结果表明, top-top-BN构型界面上的键为较强共价键, 其界面结合强度比TiN(111)板层或TiN块体材料的(111)晶面间的结合强度大, 说明此构型具有强界面特征.

关键词: 纳米复合薄膜 氮化物 界面 第一性原理

FIRST-PRINCIPLES CALCULATION OF ELECTRONIC STRUCTURE, BONDING CHARACTERISTIC AND BONDING STRENGTH OF TiN(111)/BN/TiN(111) INTERFACE

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Abstract:

The nanocomposite nc-TiN/a-BN as a representation of the family of superhard nitride-based nanocomposites, which is a nanocomposite thin film material, exhibits a significant hardness enhancement as compared with the pure constituents. In this paper, first-principles calculations were performed to investigate the role of interfaces in the nanocomposite 'nc-TiN/a-BN', to which less attention has been paid up to now. In order to determine theoretically the stable interface configuration in 'nc-TiN/a-BN', 16 possible theoretical TiN(111)/BN/TiN(111) sandwich interface configurations have been constructed based on the structure characteristic of 'nc-TiN/a-BN'. It is found in this calculation that the most favorable interface configuration is top-top-BN, which is closely related to each B atom covalently bonding to its tetrahedrally coordinated N atoms in its electronic structure is calculated. The calculated results show that the bonds at the interface in 'top-top-BN' configuration are covalent. Its interface bonding strength is higher than that between two 111 crystalline planes in slab TiN or bulk TiN.

Keywords: nanocomposite film nitride interface first principle

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